**Supporting Information** 

## Performance Characterization of Transparent and Conductive Grids One-Step-Printed on Curved Substrates Using Template-Guided Foaming

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## **Supporting Figure**



**Figure S1. Fabrication process of the conductive grids using the TGF method.** (a) Schematic of photolithography used for fabricating an SU-8 master mold and soft lithography used for fabricating a PDMS mold. (b) Schematic of the fabrication of OSTEMER membranes with through-hole and post arrays using the PDMS mold.

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